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IMAPS - International Microelectronics Assembly and Packaging Society 17 rue de l'Amiral Hamelin - 75016 Paris - France Mob: +33 (0) 7 88 75 59 86 imaps.france@orange.fr - www.france.imapseurope.org

## Wednesday June 7th

8h45 Welcome to MiNaPAD

9h00 Opening by Jean-Marc YANNOU (Auditorium)

9h30 Keynote: Laurent HERARD (STMicroelectronics – BEMT R&D Manager)

Packaging innovation – A key enabler for future mobility

# 10h15 – 10h40 Exhibition Opening (Exhibition Hall) / Coffee break sponsored by



	SESSION A: Wafer Level Packaging & Flip Chip	SESSION B: Characterization & Reliability
	(Auditorium)	(Mont Blanc)
10h45	Advanced vertical interconnections for fan-out	Comparative study on electrical performance of wire-
	wafer level packaging applications	bonded BGA packages using non-plating line vs etch-
	(Aurelia Plihon / CEA-Leti - France)	back technology
		(Damian Halicki / STMicroelectronics - Italy)
11h15	Advanced Package Platform VIPACK: FOSiP	Comparative study of thermal fatigue life of polymer
	(Chin-Cheng Kuo /ASE group - Taiwan)	core solder balls (PCSB) and SAC solder balls in BGA
		interconnections
11h45	Packaging of a 25 flip chips module on large	(I. Malkorra / ESME - France)
	dimension AIN ceramic substrate keeping low	Thermal characteristic study of epoxy molding
	dead areas and tight planarity	compound with different filler composition
	(Sarah Renault /CEA-Leti – France)	(Bo Yu Huang / ASE group - Taiwan)
		Finite elements analysis of solder joints during
12h15	Fabrication and characterization of a 2 layers	thermal shock tests correlation with dye penetration
	face-to-back test vehicle with high density TSV	(Khalil Maarouf / VALEO - France)
	(Jerzy-Javier Suarez-Berru / CEA-Leti - France)	

### 12h45 – 13h35 Lunch (Exhibition Hall) sponsored by

	SESSION C: Interconnections (Auditorium)	SESSION D: MEMs & Optical Packages (Mont Blanc)
13h40	The study of pure Cu and Pd coated Cu wire- bonding on nano-twinned Cu pad/finger (Erh-Ju Lin / ASE group - Taiwan)	Test on package: design and manufacturing of package aimed to electromechanical characterization of MEMS structures  (Marco Del Sarto / STMicroelectronics – Italy)
14h10	Cu second bond response on thin silver pre- plated leadframe packages (Mirko Alesi / STMicroelectronics - Italy)	3D silicon photonic interposer process integration for chiplet based 3D systems (Damien Saint-Patrice / CEA-Leti - France) Wafer level optical package for ambient light sensor
14h40	Next generation lead-free solder paste for advanced packages (B. Senthil Kumar / HERAEUS - Germany)	for mobile and wearable applications with integrated multi-lens array (Niek van Haare / BESI - Netherlands)
15h10	Multiphase full wave system (Jean-Christophe Riou / SAFRAN - France)	3D heterogeneous integration of meta surface lens in an optical package (Patrick Laurent / STMicroelectronics - France)

#### 15h40 - 16h00 Exhibition / Coffee break sponsored by

## SESSION E: Panel Session (Auditorium)

**16h05** Writing Invention Disclosures to Optimize Patent Value in Europe and the U.S

(Richard P. Gilly / Archer & Greiner P.C. - USA)

**16h30** Advanced packaging technology & market trends

(Bilal Hachemi / YOLE Developments - France)

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16h55 Round Table: The Reindustrialization of Semiconductor Packaging in Europe in the context

of the EU Chips Act

Moderator: BOULAY Sanae (NXP) and De LANGLADE Renaud (EPOSS)

**Speakers:** IBRAHIM Mario (AT&S), OBERNDORFF Pascal (NXP), HERARD Laurent (STMicroelectronics), YANNOU Jean-Marc (ASE Europe), David HIEN (EGIDE)

18h00

18h30 Social Event : Château de la Commanderie

Sponsored by

Leti ceatech TECHNOLOGY RESEARCH INSTITUTE

18h30-19h00: Transportation by FAURE Bus from WTC conference

19h00-20h00: Appetizers & Music by Alpes concerts

20h00: Dinner

22h30: Return to WTC conference by FAURE Bus





Overview Château de la Commanderie (38320 EYBENS)



### Thursday June 8th

#### 8h30 - Opening exhibition and conferences

**Session F: Encapsulation Session G: BGA manufacturing** (Mont Blanc) (Auditorium) 08h45 The phenomenon of creep and overflow in gel Advanced IC substrates - challenges in dispense process manufacturing and supply chain (Shih Kun Lo / ASE group - Taiwan) (Daniel Schulze / DYCONEX - Switzerland) Fabrication and characterization of soft polymer 09h15 Enabling semiconductor packaging materials for advanced flip-chip and heterogeneous core solder balls (PCSB) for BGA integration interconnections (I. Malkorra / ESME - France) (Ruud de Wit / HENKEL - Netherland)

9h50 Keynote: Pascal OBERNDORFF (NXP – Head of Package Core Technology)
Title

# 10h30 – 10h50 Exhibition & Coffee break (Exhibition Hall) sponsored by

Session H: Manufacturing - Plasma **Session I: Manufacturing - Equipment's** (Auditorium) (Mont Blanc) 10h55 Panasonic plasma cleaning technology and Advanced laser grooving and dicing to enable predictive maintenance by using plasma high quality separation of next generation thin monitor function semiconductor devices (James Weber / PANASONIC - Germany) (Gerald Klug / DISCO – Germany) 11h25 Cleaning of silicone and hydrocarbon contact Direct writing technologies for interconnection residue using atmospheric plasma in electronic packaging (Daniel Pascual / ONTOS Equipment Systems -(Elodie Pereira / CTTC - France) USA) 11h55 Improving CCP chamber-plasma-cleaning An innovative contactless technology for high performance using plasma light emission (OES) resolution, high speed, conductive & dielectric materials deposition (Jong Won Oh / VISION Semicon - Republic of (Stéphane Etienne / I-O-TECH, Israel)

#### 12h25 - 13h30 Lunch & Exhibition (Exhibition Hall) sponsored by

Korea)



## Session J: Advanced Interconnections (Auditorium)

13h35	Development of stretchable and removable electrical interconnection solution for ultra-thin electronic components
	(Auriane Despax-Ferreres / CEA-LITEN - France)
14h05	High density interconnect above active CMOS structures utilizing optimized klettwelding of nanowires
	(Andreas Kramer / TU Darmstadt - Germany)
14h35	The failure mechanism of μ-CuP employed in sensor packages
	(Erh-Juh Lin / ASE group - Taiwan)
15h05	Hybrid in-mold electronics process towards novel 3d packaging of components and systems
	(Philippe Lombard / University of Lyon - France)

15h35 Closing by Jean-Marc YANNOU (Auditorium)

15h40 -16h00 Exhibition /Coffee Break
16h00 End of MiNaPAD 2023 conference

## **List of Exhibitors**

### 28/04/2023

Booth number	Company		
1	ASE		
2	ELECTRON-MEC		
3			
4	DAVUM - Option		
5			
6	INTRASPEC - Option		
7	PROTAVIC		
8	MST		
9	ELEMCA		
10	METRONELEC		
11	CTS - Option		
12	SET		
13	KYOCERA		
14	NITERRA / NTK		
15	ACCELONIX		
16	AEMTEC		
17	EGIDE		
18	DISCO		
19	TAIPRO		
20	ISP SYSTEM		
21	BT ELECTRONICS		
	POLY DISPENSING SYSTEMS		
22	TELEDYNE E2V		
23	HYBRID		
24	MICROTEST		
	ONTOS		
25 NANOTEC			
26	SERMA Microelectronics		
27	MICRONOR		
28	CEA		
29	FINETECH		
30	JCET Group Co., Ltd		



### **REGISTRATION FORM**

O Mrs,	O M.				
Name: Company: Job Title:	Firstname:				
Zip: Email:	City	Country			
Individual registration: By email: <u>imaps.france@orange.fr</u> By Post: IMAPS, 17 rue de l'Amiral Hamelin, 75016 Paris By Internet: <u>https://event.imaps.france.org</u>					
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Speakers: O 180 € VAT excl. Please confirm your a	attendance to social e	vent □			
Chairs, Technical Cor O 320 € VAT excl. Please confirm your a	<b>nmittee:</b> attendance to social e	vent □			
O 380 € VAT excl.	PS 2023 and IEEE 202 attendance to social e				
Non IMAPS Member O 480 € VAT excl. Please confirm your a	attendance to social e	vent □			
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